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# Preparation of oligosilanes containing perhalogenated silvl groups $(-SiX_3, -SiX_2-, \geq SiX-, X = Cl, Br)$ and their hydrogenation by stannanes

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## Abstract

Starting from methylphenylsubstituted oligosilanes the disilanes  $SiX_3-SiX_iMe_{3-i}$  (i = 0, 1, 2; X = Cl, Br), trisilanes  $SiX_2(SiX_iMe_{3-i})$  (i = 0, 1) and branched tetrasilanes  $SiX(SiXMe_2)_3$  were synthesized and their behavior towards the Lewis-base catalyzed hydrogenation by stannanes was investigated. In the case of methylchlorodisilanes  $SiCl_3-SiCl_iMe_{3-i}$  Si-Si bond cleavage competes with the hydrogenation reaction. © 1997 Elsevier Science S.A.

Keywords: Silicon; Oligosilanes; Perhalogenated silyl groups

# 1. Introduction

The Lewis-base catalyzed hydrogenation of methylchlorooligosilanes as well as methylbromooligosilanes with trialkylstannanes is a very useful method to provide partially as well as completely hydrogenated oligosilanes [1-3]. The formed product distribution depends on the starting molar ratio stannane: oligosilane, on the used catalyst and stannane.

But until now only few results are known about the hydrogenation of oligosilanes bearing completely halo-

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gen substituted silicon units. Only the hydrogenation of hexachlorodisilane with tri-n-butylstannane has been investigated.

In the presence of a catalytically more active Lewisbase catalyst a cleavage of the Si–Si bond, presumably according to the mechanism described in Ref. [4] dominates followed by a partial hydrogenation of the primarily formed SiCl<sub>4</sub> [5]. The structure of the as formed higher oligosilanes was not investigated, but it is known from Refs. [6,7] that the Lewis-base catalyzed disproportionation of hexachlorodisilane leads to SiCl<sub>4</sub> and mainly Si(SiCl<sub>3</sub>)<sub>4</sub>:

$$SiCl_3 - SiCl_3 + |D \rightarrow SiCl_4 + D - : SiCl_2$$
 (2)

$$SiCl_3 - SiCl_3 + 3D - SiCl_4$$

$$\rightarrow \text{SiCl}_3 - \text{Si}(\text{SiCl}_3)_3 + 3|\text{D}$$
(3)

In this sense it was interesting to evaluate to which extend the disproportionation dominates the hydrogenation of other disilanes bearing one SiCl<sub>3</sub> unit (SiCl<sub>3</sub>–SiCl<sub>i</sub>Me<sub>3-i</sub>) and to compare the results with those ones of the hydrogenation of methylbromodisilanes SiBr<sub>3</sub>–SiBr<sub>i</sub>Me<sub>3-i</sub>. Furthermore the investigation of the hydrogenation reactions of some other oligosilanes having perhalogenated silylgroups (e.g. SiCl<sub>i</sub>Me<sub>3-i</sub>–SiCl<sub>2</sub>–SiCl<sub>i</sub>Me<sub>3-i</sub>, SiCl(SiClMe<sub>2</sub>)<sub>3</sub>, cyclo-(SiCl<sub>2</sub>)<sub>5</sub>) should display, whether the disproportionation is a serious

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problem concerning only the hydrogenation of silanes bearing terminal  $SiX_3$  units (X = Cl, Br) or not.

From the hydrogenation of trisilanes bearing one halogen substituent at the middle silicon atom (-SiXMe- units) it is known [2,3,8] that this one is hydrogenated by stannanes at first.

$$\begin{array}{c} CI CI CI \\ Me \cdot Si - Si - Si - Me \\ CI Me CI \end{array} \xrightarrow{Me_3SnH [R_4PX]} CI H CI \\ - Me_3SnCI \\ CI Me CI \end{array} \xrightarrow{CI H CI \\ Me \cdot Si - Si - Si - Me \\ CI Me CI \end{array}$$
(4)

$$\begin{array}{c} \text{Br Br Br}\\ \text{Me} \cdot \text{Si-Si-Si-Me}\\ \text{MeMeMe} \end{array} \xrightarrow[]{} \begin{array}{c} \text{Me}_{3}\text{SnH}\left[\text{R}_{4}\text{PX}\right]\\ -\text{Me}_{3}\text{SnBr} \end{array} \xrightarrow[]{} \begin{array}{c} \text{Br H Br}\\ \text{Me} \cdot \text{Si-Si-Si-Me}\\ \text{MeMeMe} \end{array} (5)$$

This regioselectivity should also result in the cases of oligomers having  $-SiX_2$  as well as >SiX units beside halogen substituents at the terminal silicon atoms.

# 2. Results and discussion

2.1. Hydrogenation of disilanes having one  $SiX_3$  unit (X = Cl, Br)

All attempts to hydrogenate 1,1,1-trichlorotrimethyldisilane with stannanes (Me<sub>3</sub>SnH, Bu<sub>3</sub>SnH) in presence of catalysts as Ph<sub>3</sub>MePI, Ph<sub>3</sub>P, bipy led only to a complete cleavage of the Si–Si bond. Exclusively Me<sub>3</sub>SiCl resulted as volatile product:

$$Me_{3}Si-SiCl_{3} + |D \rightarrow Me_{3}SiCl + [D - :SiCl_{2}]$$
(6)

The structure of the eventually formed higher oligosilanes was not investigated yet.

Unlike this reaction the hydrogenation of 1,1,1,2-tetrachlorodimethyldisilane and pentachloromethyldisilane with Bu<sub>3</sub>SnH (molar ratio 1:3) and Ph<sub>3</sub>P as catalyst yielded partially hydrogenated disilanes and only little amounts (40% and 20%, respectively) of methylchloromonosilanes resulting from a disproportionation of the disilane:

$$Me_{2}ClSi-SiCl_{3} \xrightarrow{3Me_{3}SnH[Ph_{3}P]} Me_{2}ClSi-SiH_{3}$$
  
beside Me\_{2}SiCl\_{2} (7)

$$MeCl_{2}Si-SiCl_{3} \xrightarrow{3Me_{3}SnH[Ph_{3}P]} MeCl_{2}Si-SiH_{3}$$
  
beside MeSiCl\_{3} (8)

Not a trace of other partially hydrogenated disilanes could be indicated by means of <sup>29</sup>Si NMR spectroscopy.

If the hydrogenations were carried out with the analog methylbromodisilanes no Si–Si bond cleavage could be observed:

$$Me_{3}Si-SiBr_{3} \xrightarrow{3Me_{3}SnH[Ph_{3}P]} Me_{3}Si-SiH_{3}$$
(9)

$$Me_2BrSi-SiBr_3 \xrightarrow{3Me_3SnH[Ph_3P]} Me_2BrSi-SiH_3$$

and 
$$Me_2HSi-SiH_3$$
 (10)

$$MeBr_{2}Si-SiBr_{3} \xrightarrow{3Me_{3}SnH[Ph_{3}P]} MeBr_{2}Si-SiH_{3}$$
  
and MeH\_{2}Si-SiH\_{3} (11)

These results exhibit, that the tendency of disilanes to give base catalyzed Si–Si bond cleavage rises with the polarity of the Si–Si bond rather than with an increase of the total number of electron withdrawing substituents. This conclusion parallels the observation in Ref. [4], where SiCl<sub>2</sub>Me–SiClMe<sub>2</sub> is cleaved preferably to SiCl<sub>2</sub>Me–SiCl<sub>2</sub>Me and SiClMe<sub>2</sub>–SiClMe<sub>2</sub>. Due to

no Si-Si bond cleavage occurs in methylbromodisilanes. The hydrogenation in disilane molecules having one  $SiX_3$  unit starts in all investigated examples exclusively at this group and leads only to the completely hydro-

genated SiH<sub>3</sub> unit.

the less electron drawing effect of bromine substituents



Scheme 1. Hydrogenation of the trisilanes  $SiX_2(SiXMe_2)_2$ , X = Cl, Me/Br.

| Compound  | $\delta_{SiA}$ | $\delta_{SiB}$     | ${}^{1}J_{SiSi}$ | $\delta_{\mathrm{HSi}^{\mathrm{A}}\mathrm{H}}$ | $\delta_{HSi^BH}$ | $\delta_{\rm HCH_3}$     |
|---|----------------|--------------------|------------------|--|-------------------|--------------------------|
| Si <sup>A</sup> Cl <sub>3</sub> Si <sup>B</sup> Me <sub>3</sub>               | 17.54          | -7.15 <sup>a</sup> | 115.7            |  |                   | 0.25                     |
| Si <sup>A</sup> Cl <sub>3</sub> Si <sup>B</sup> ClMe <sub>2</sub>             | 7.82           | 15.67              | 150.6            |  |                   | 0.60                     |
| Si <sup>A</sup> Cl <sub>3</sub> Si <sup>B</sup> Cl <sub>2</sub> Me            | -0.22          | 14.01              | 245.6            |  |                   | 0.95                     |
| Si <sup>A</sup> Br <sub>3</sub> Si <sup>B</sup> Me <sub>3</sub>               | - 3.40         | -1.38              |                  |  |                   | 0.28                     |
| Si <sup>A</sup> Br <sub>3</sub> Si <sup>B</sup> BrMe <sub>2</sub>             | - 18.64        | 10.90              | 127              |  |                   | 0.78                     |
| Si <sup>A</sup> Br <sub>3</sub> Si <sup>B</sup> Br <sub>2</sub> Me            | -29.19         | 0.54               |                  |  |                   | 1.25                     |
| Si <sup>A</sup> H <sub>3</sub> Si <sup>B</sup> Me <sub>3</sub>                | - 98.07        | -17.09             |                  | 3.17   |                   | 0.11                     |
| Si <sup>A</sup> H <sub>3</sub> Si <sup>B</sup> HMe <sub>2</sub>               | - 98.47        | - 40.56            |                  | $3.19^{3}J_{\rm HH}$ : 2.4                     | 3.95              | $0.10^{-3} J_{\rm HH}:5$ |
| Si <sup>A</sup> H <sub>3</sub> Si <sup>B</sup> H <sub>2</sub> Me <sup>b</sup> | -100.67        | -70.12             |                  | $3.25 {}^{3}J_{HH}$ : 3.1                      | 3.69              | $0.07^{3}J_{HH}: 4.9$    |
| Si <sup>A</sup> H <sub>3</sub> Si <sup>B</sup> ClMe <sub>2</sub>              | -95.24         | 21.40              |                  | 3.24   |                   | 0.39                     |
| Si <sup>A</sup> H <sub>3</sub> Si <sup>B</sup> BrMe <sub>2</sub>              | -93.35         | 13.53              |                  | $3.36 I_{SiH}: -196$                           |                   | 0.48                     |
| Si <sup>A</sup> H <sub>3</sub> -Si <sup>B</sup> Cl <sub>2</sub> Me            | - 90.68        | 29.99              |                  | $3.29^{-1}J_{\text{SiH}}^{\text{SiH}}$ : -204  |                   | 0.57                     |
| Si <sup>A</sup> H <sub>3</sub> Si <sup>B</sup> Br <sub>2</sub> Me             | -86.06         | 13.01              |                  | 3.56   |                   | 0.88                     |

NMR data of the disilares SiX<sub>1</sub>-SiX<sub>2</sub>Me<sub>2</sub>, X = Cl. Br. H; i = 0, 1, 2 (chemical shifts in nom and coupling constants in Hz)

Table 1

<sup>a</sup>  ${}^{1}J_{SiC}$ : 49.2 Hz. <sup>b</sup>  ${}^{29}Si$  and  ${}^{1}HNMR$  data already known from Ref. [12].

2.2. Hydrogenation of trisilanes containing a  $-SiX_2$ unit

The hydrogenation of  $SiCl_2(SiMe_3)_2$  with  $Me_3SnH$ provides pure SiH<sub>2</sub>(SiMe<sub>3</sub>)<sub>2</sub>. Any cleavage of Si-Si bonds could not be observed:

$$\operatorname{SiCl}_{2}(\operatorname{SiMe}_{3})_{2} \xrightarrow{\operatorname{2Me}_{3}\operatorname{SnH}[\operatorname{Ph}_{3}\operatorname{MePI}]-2\operatorname{Me}_{3}\operatorname{SnCl}} \operatorname{SiH}_{2}(\operatorname{SiMe}_{3})_{2}$$
(12)

Our attempts to produce SiHCl(SiMe<sub>3</sub>)<sub>2</sub> failed. The hydrogenation of  $SiCl_2(SiMe_3)_2$  with one equivalent Me<sub>3</sub>SnH yields a mixture of 50% SiCl<sub>2</sub>(SiMe<sub>3</sub>)<sub>2</sub> and 50% SiH<sub>2</sub>(SiMe<sub>3</sub>)<sub>2</sub>.

Starting with  $SiX_2(SiXMe_2)_2$  (X = Cl, Br) the reaction with two equivalents Me<sub>3</sub>SnH leads exclusively to  $SiH_2(SiXMe_2)_2$ . A stepwise hydrogenation of the terminal Si-halogen bonds occurs, if more stannane is added. This course was also observed for SiMe<sub>3</sub>- $SiCl_2-SiClMe_2$  (in mixture with  $SiCl_2(SiClMe_2)_2$  and parallels the results of the hydrogenation of trisilanes bearing a -SiXMe- unit [2,3] (Scheme 1). Ph<sub>3</sub>MePI was used as a catalyst.

# 2.3. Hydrogenation of isotetrasilanes containing a tertiary >SiX- unit

As expected, the hydrogenation of  $SiX(SiXMe_2)_3$ (X = Cl, Br) with one equivalent Me<sub>3</sub>SnH (Ph<sub>3</sub>MePI as catalyst) provides SiH(SiXMe<sub>2</sub>)<sub>3</sub> exclusively. Reaction with an excess of Me<sub>3</sub>SnH yields the completely hydrogenated molecule SiH(SiHMe<sub>2</sub>)<sub>3</sub>:

$$Cl - Si - SiMe_{2} - Cl$$

$$SiMe_{2} - Cl$$

$$SiMe_{2} - Cl$$

$$SiMe_{2} - Cl$$

$$-Me_{3}SnCl$$

$$H - Si - SiMe_{2} - Cl$$

$$SiMe_{2} -$$

$$Br - Si - SiMe_2 - Br$$

$$Br - Si - SiMe_2 - Br$$

$$SiMe_2 - Br$$

$$SiMe_2 - Br$$

$$-Me_3SnBr$$

$$H - Si - SiMe_2 - Br$$

$$SiMe_2 - H$$

$$H - Si - SiMe_2 - H$$

$$SiMe_2 - H$$

$$SiMe_2 - H$$

$$SiMe_2 - H$$

$$SiMe_2 - H$$

# 2.4. Hydrogenation of cyclo- $(SiCl_2)_5$

The reaction of  $cyclo-(SiCl_2)_5$  with  $Me_3SnH$ (Ph<sub>3</sub>MePI as catalyst) results in a stepwise hydrogenation of SiCl<sub>2</sub> units to SiH<sub>2</sub> units. The assignment of the <sup>29</sup>SiNMR signals especially in the SiCl<sub>2</sub> region was very difficult and only possible by comparison of the spectra of mixtures with different molar ratios  $Me_3SnH: Si_5Cl_{10}$  (1:2, 1:4, 1:6, 1:8). Any formation of products containing SiHCl units was not indicated in the <sup>29</sup>Si NMR spectra (no signal in the expected chemical shift range for -SiHCl-). The dominating product in the stepwise hydrogenation is 1,1,3,3-tetrachlorocyclopentasilane, whereas 1,1,2,2,3,3,4,4-octachlorocyclopentasilane could not be detected. With an excess of Me<sub>3</sub>SnH the previously known [9]  $(SiH_2)_5$  is formed.

## 2.5. NMR measurements

Even though the investigated methylchlorodisilanes and methylbromodisilanes are relatively small and sim-

Table 2 NMR data of further methylbromodisilanes

|  | -                                |                                  |                    |               |                 |
|--|----------------------------------|----------------------------------|--------------------|---------------|-----------------|
| Compound   | $\delta_{\mathrm{Si}\mathrm{A}}$ | $\delta_{\mathrm{Si}\mathrm{B}}$ | $^{1}J_{\rm SiSi}$ | $\delta_{HA}$ | δ <sub>HB</sub> |
| Si <sup>A</sup> BrMe <sub>2</sub> Si <sup>B</sup> Me <sub>3</sub> <sup>a</sup> | 17.97                            | - 17.71                          | 92                 | 0.48          | 0.11            |
| SiBrMe <sub>2</sub> -SiBrMe <sub>2</sub> <sup>a</sup>                          | 10.47                            |                                  |                    | 0.54          |                 |
| $Si^{A}Br_{2}Me-Si^{B}Me_{3}$  | 23.92                            | - 11.49                          | 103                | 1.04          | 0.20            |
| Si <sup>A</sup> Br <sub>2</sub> Me-Si <sup>B</sup> BrMe <sub>2</sub>           | 11.11                            | 8.38                             |                    | 1.11          | 0.68            |
| SiBr <sub>2</sub> Me-SiBr <sub>2</sub> Me <sup>a</sup>                         | 2.84                             |                                  |                    | 1.18          |                 |

<sup>a</sup> NMR data already published in Ref. [3].

| Table 3 | ,        |      |            |  |         |
|---------|----------|------|------------|--|---------|
| NMR d   | lata of  | the  | trisilanes | $\operatorname{SiX}_{i}\operatorname{Me}_{3-i}-\operatorname{SiX}_{2}-\operatorname{SiX}_{i}\operatorname{Me}_{3-i}$ | X = Cl, |
| Br. H:  | i = 0, 1 | 1: i | = 0, 1     | , - <u>,</u>   |         |

| Compound   | $\delta_{\rm Si}$  | <sup>1</sup> J <sub>SiSi</sub> | $\frac{\delta_{\rm H}}{^{3}J_{\rm HH}}$ SiMe/ | δ <sub>H</sub> SiH |
|--|--------------------|--------------------------------|---|--------------------|
| Si <sup>A</sup> Cl <sub>2</sub> (Si <sup>B</sup> Me <sub>3</sub> ) <sub>2</sub> <sup>a</sup>       | A: 34.51           | 76                             | 0.211   |                    |
|  | B: -11.42          |                                | ${}^{1}J_{\rm SiC}$ : 45.6                    |                    |
| $\mathrm{Si}^{\mathrm{A}}\mathrm{H}_{2}(\mathrm{Si}^{\mathrm{B}}\mathrm{Me}_{3})_{2}^{\mathrm{a}}$ | A: -103.88         | 69                             | 010   | 2.67               |
|  | B: -14.12          |                                | 0.195   |                    |
| $Si^{A}Cl_{2}(Si^{B}ClMe_{2})$ -<br>( $Si^{C}Me_{2}$ )   | A: 23.37           |                                |   |                    |
| ۰. رو ۲.   | B: 17.45           |                                | 0.546   |                    |
|  | C: -9.67           |                                | 0.228   |                    |
| $Si^{A}H_{2}(Si^{B}ClMe_{2})$ -<br>$(Si^{C}Me_{2})$  | A: -101.09         |                                |   | 2.91               |
| (01 1.103)   | B: 26.7            |                                | 0.54  |                    |
|  | $C_{1} = 13.9$     |                                |   |                    |
| $Si^{A}H_{2}(Si^{B}HMe_{2})$ -<br>$(Si^{C}Me_{2})$   | A: -104.62         |                                | -/2.9 <sup>b</sup>                            | 2.74               |
| · 3/   | <b>B</b> : - 38.10 |                                | 0.181   | 3.98               |
|  | C: -13.93          |                                | 0.140   |                    |
| $Si^{A}Cl_{2}(Si^{B}ClMe_{2})_{2}^{a}$   | A: 13.44           | 98                             |   |                    |
| 2 2 2 2  | B: 17.38           |                                | 0.599   |                    |
| $Si^{A}H_{2}(Si^{B}ClMe_{2})_{2}$  | A: -97.91          |                                |   | 3.15               |
| 2 2 2 2  | B: 24.52           |                                | 0.545   |                    |
| $Si^{A}H_{2}(Si^{B}HMe_{2})-$<br>( $Si^{C}ClMe_{2}$ )  | A: -101.52         |                                | -/2.7 <sup>b</sup>                            | 2.98               |
| 27   | B: -38.41          |                                | 0.220/4.3                                     | 3.98               |
|  | C: 26.21           |                                | 0.54  |                    |
| $Si^{A}Br_{2}(Si^{B}BrMe_{2})_{2}$   | A: -4.31           | 90                             |   |                    |
| 2 2 2 2  | B: 9.15            |                                |   |                    |
| $Si^{A}H_{2}(Si^{B}BrMe_{2})_{2}$  | A: -94.62          |                                |   |                    |
| 2 2 2 2  | B: 17.33           |                                |   |                    |
| $Si^{A}H_{2}(Si^{B}HMe_{2})_{2}$   | A: -105.81         | 68                             | -/2.85 <sup>b</sup>                           | 2.81               |
| £ · 2·2  | B: - 38.01         |                                | 0.181/4.4                                     | 3.98               |

<sup>a 29</sup>SiNMR shifts and <sup>1</sup> $J_{SiSi}$  already given in Ref. [10].

<sup>b</sup> Coupling constant  ${}^{3}J_{\text{Hi}-\text{Si}^{A}-\text{Si}^{B}-\text{H}}$ .

ple molecules as far as we know no <sup>29</sup>Si NMR chemical shifts has been reported until now. Only <sup>1</sup>H NMR data of SiCl<sub>3</sub>–SiCl<sub>i</sub>Me<sub>3-i</sub> (i = 0, 1, 2) has been given in Ref. [10]. In order to complete the NMR data of the series of methylbromodisilanes 1,1-dibromotetramethyl-



Fig. 1. <sup>29</sup>Si NMR chemical shifts in methylchlorodisilanes  $SiCl_iMe_{3-i}$ -SiCl<sub>i</sub>Me<sub>3-i</sub>.



Fig. 2. <sup>29</sup>Si NMR chemical shifts in methylbromodisilanes  $SiBr_iMe_{3-i}SiBr_iMe_{3-j}$ .

disilane and 1,1,2-tribromotrimethyldisilane were prepared, too. Tables 1 and 2 show the results of our NMR measurements of disilanes.

The found NMR data of trisilanes, Table 3, fit well the trends of previously published data for instance in Ref. [11].

The substitution of a methyl group by a hydrogen atom causes an upfield shift on the neighbour Si atom, the opposite signal moving happens if a methyl group is substituted by a halogen atom. (See Figs. 1-3.)

# 3. Experimental

## 3.1. Preparation of methylphenyloligosilanes

1,1-diphenyltetramethyldisilane and 1,1,1-triphenyltrimethyldisilane were prepared according to Ref. [14].

NMR: SiPh<sub>2</sub>Me–SiMe<sub>3</sub>:  $\delta_{Si}$ : -21.3 ppm, -18.3 ppm,  $\delta_{H}$ : 0.22 ppm (9H), 0.66 ppm (3H), 7.2–7.6 ppm (10H); SiPh<sub>3</sub>–SiMe<sub>3</sub>:  $\delta_{Si}$ : -20.6 ppm, -18.6 ppm,  $\delta_{H}$ : 0.23 ppm (9H), 7.2–7.6 ppm (15H).



Fig. 3. <sup>29</sup>SiNMR chemical shifts of  $\underline{SiH}_i(SiX_jMe_{3-j})_{4-i}$ , i = 1, 2, 3.

T-1.1. 1

Table 4 NMR data of the isotetrasilanes  $SiX(SiXMe_2)_3$ , X = Cl, H/Br, H

| Compound   | $\delta_{SiA}$ | <sup>1</sup> J <sub>SiSi</sub> | $\delta_{SiB}$ |  |
|--|----------------|--------------------------------|----------------|--|
| $Si^{A}Cl(Si^{B}ClMe_{2})_{3}$   | -24.38         | 77                             | 22.12          |  |
| $Si^{A}H(Si^{B}ClMe_{2})_{3}$  | - 104.32       | 69                             | 26.09          |  |
| $Si^{A}H(Si^{B}HMe_{2})_{3}$   | -118.91        |                                | - 35.54        |  |
| $Si^{A}Br(Si^{B}BrMe_{2})_{3}$   | -40.09         |                                | 12.71          |  |
| $\operatorname{Si}^{A} H(\operatorname{Si}^{B} \operatorname{Br} \operatorname{Me}_{2})_{3}$ | - 100.00       |                                | 18.09          |  |
|  |                |                                |                |  |

## 3.1.1. 2,2-diphenylhexamethyltrisilane

A mixture of 20 g  $Ph_2SiCl_2$  and 200 g  $Me_3SiCl$  was added to 3.46 g Li powder in 100 ml dried tetrahydrofurane. After stirring over night the mixture was filtered from LiCl. Excess  $Me_3SiCl$  and THF were separated from the residue of  $SiPh_2(SiMe_3)_2$  by distillation.

Yield: 27 g (66%), GC/MS (m/e, rel. int.): 328 ( $M^+$ , 47), 313 ( $Si_3Me_5Ph_2$ , 12), 255 ( $Si_2Me_3Ph_2$ , 100), 225 ( $Si_2MePh_2$ , 9), 197 ( $SiMePh_2$ , 53), 178 ( $Si_2Me_3Ph$ , 67), 163 ( $Si_2Me_2Ph$ , 66), 135 ( $SiMe_2Ph$ , 87), 105 (SiPh, 28), 73 ( $SiMe_3$ , 35).

NMR:  $\delta_{Si}$ : - 38.7 ppm (SiPh<sub>2</sub>), - 16.0 ppm (SiMe<sub>3</sub>).

# 3.1.2. Tris-(trimethylsilyl)-phenylsilane

A mixture of 25 g PhSiCl<sub>3</sub> and 250 g Me<sub>3</sub>SiCl was added to 6.9 g Li powder in 100 ml dried tetrahydrofurane. After stirring over night the mixture was filtered from LiCl and fractionated to yield 27 g (50%) SiPh(SiMe<sub>3</sub>)<sub>3</sub>. B.p. 200–210°C/0.6 kPa.

GC/MS (m/e, rel. int.): 324 (M<sup>+</sup>, 31), 309 (Si<sub>4</sub>Me<sub>8</sub>Ph, 10), 251 (Si<sub>3</sub>Me<sub>6</sub>Ph, 12), 236 (Si<sub>3</sub>Me<sub>5</sub>Ph, 15), 221 (Si<sub>3</sub>Me<sub>4</sub>Ph, 8), 191 (Si<sub>3</sub>Me<sub>2</sub>Ph, 23), 174 (Si<sub>3</sub>Me<sub>6</sub>, 100), 159 (Si<sub>3</sub>Me<sub>5</sub>, 37), 135 (SiMe<sub>2</sub>Ph, 78), 73 (SiMe<sub>3</sub>, 96).

NMR:  $\delta_{Si}$ : -76.8 ppm (SiPh), -12.8 ppm (SiMe<sub>3</sub>)  ${}^{1}J_{SiSi}$ : 62 Hz,  $\delta_{H}$ : 0.21 ppm (27H), 7.2-7.7 ppm (5H).

## 3.1.3. Decaphenylcyclopentasilane

126.5 g  $Ph_2SiCl_2$  were added to 6.9 g Li powder in 200 ml THF. After stirring over night the mixture was filtered and THF removed in vacuo. The residue was dissolved in toluene, filtered and the toluene removed in vacuo to yield 48 g (53%) Si<sub>5</sub>Ph<sub>10</sub>. <sup>29</sup>SiNMR: one signal at -34 ppm (-34.4 ppm [13]).

# 3.2. Preparation of methylchlorooligosilanes and methylbromooligosilanes

All methylchlorooligosilanes as well as methylbromooligosilanes were prepared starting from phenylmethyloligosilanes by action of acetyl chloride plus aluminiumchloride or acetyl bromide plus aluminiumbromide, respectively. After the conversion was complete, n-hexane was added to extract the as formed halogenated oligosilane out of the residue of acetone and acetophenone aluminiumhalogenide complex (X = Cl, Br):

$$R_{3}Si-Me + Me-COX + AIX_{3}$$
  

$$\rightarrow R_{3}Si-X + Me-CO-Me \cdot AIX_{3}$$
(15)  

$$R_{3}Si-Ph + Me-COX + AIX_{3}$$

$$\rightarrow$$
 R<sub>3</sub>Si–X + Ph–CO–Me · AlX<sub>3</sub>

Because Si-Ph bonds are much more reactive towards acetyl halide than Si-Me bonds, all Si-Ph bonds were transformed first.

The hexane phase was separated and the solvent could easily be removed from the desired silane by condensation in vacuo.

The NMR data of the products are summarized in Tables 1-5.

# 3.2.1. 1,1,1-trichlorotrimethyldisilane, 1,1,1,2-tetrachlorodimethyldisilane and pentachloromethyldisilane

8.5 g SiPh<sub>3</sub>SiMe<sub>3</sub>, 10.25 g AlCl<sub>3</sub> and 6.0 g acetyl chloride yielded, after working up as described, 2.9 g (55%) pure SiCl<sub>3</sub>SiMe<sub>3</sub> (b.p.  $70^{\circ}C/3$  kPa).

The same reaction, carried out with 13.5 g  $AlCl_3$  and 8.0 g acetyl chloride at 50°C (2 h) led to 2 g (35%)  $SiCl_3$ -SiClMe<sub>2</sub> (after distillation).

Pentachloromethyldisilane can also be prepared from  $SiPh_3SiMe_3$  with  $AlCl_3$  and acetylchloride (starting molar ratio 1:6:6, 10 h at 120°C, yield 30%), but more conveniently it can be obtained from  $SiCl_2Ph-SiCl_2Me$  as it will be published in Ref. [15].

Table 5

NMR data of cyclopentasilanes  $Si_5H_iCl_{10-i}$ , i = 0, 4, 6, 8, 10

| compound   | δ <sub>Si A</sub>                | δ <sub>H</sub>   |
|--|----------------------------------|--|
| $\begin{array}{c} \operatorname{SiCl}_2 & \operatorname{SiCl}_2 & \operatorname{a} \\ \operatorname{Cl}_2 & \operatorname{SiCl}_2 & \operatorname{a} \\ \operatorname{Cl}_2 & \operatorname{SiCl}_2 & \operatorname{SiCl}_2 \end{array}$ | -1.8                             | -  |
| $\begin{array}{c} SiH_2 \\ Si^CCl_2 \\ Si^CCl_2 \\ Cl_2 \\ Si^B - Si^A \\ H_2 \end{array}$   | A: -83.5<br>B: 3.0<br>C: 8.9     | 4.00   |
| $\begin{array}{c} Si^{B}H_{2}\\ Cl_{2}Si {\checkmark} Si^{C}Cl_{2}\\ H_{2}Si {\longleftarrow} Si^{A}H_{2}\end{array}$  | A: -89.2<br>B: -78.7<br>C: 12.8  | A: 3.78<br>B: 3.91                                       |
| $Cl_2Si^{C}iH_2 SiH_2 H_2Si^{B}-Si^{A}H_2$   | A: -107.5<br>B: -87.1<br>C: 14.4 | A: 3.49<br>B: 3.74<br><sup>3</sup> J <sub>HH</sub> : 3.8 |
| $\begin{array}{c} SiH_2 \\ H_2Si \\ H_2Si \\ H_2Si \\ SiH_2 \end{array} = SiH_2 \end{array} $  | -105.7                           | 3.46   |

<sup>a</sup> <sup>29</sup>SiNMR shifts already published in Ref. [13].

(16)

## 3.2.2. 1,1-dibromotetramethyldisilane

The reaction of 5.5 g SiPh<sub>2</sub>Me–SiMe<sub>3</sub> with 10.7 g AlBr<sub>3</sub> and 4.9 g acetylbromide at room temperature provided after the usual work up and distillation 2.0 g (36%) SiBr<sub>2</sub>Me–SiMe<sub>3</sub> (b.p. 50°C/0.8 kPa, m.p. 40°C).

# 3.2.3. 1,1,2-tribromotrimethyldisilane

Bromination of 4.2 g Si<sub>2</sub>Me<sub>6</sub> with 22.9 g AlBr<sub>3</sub> and 10.6 g acetyl bromide (1 h at 120°C) yielded after distillation 7.55 g (77%) of a crystalline product containing 80% SiBr<sub>2</sub>Me–SiBrMe<sub>2</sub> beside 10% SiBrMe<sub>2</sub>–SiBrMe<sub>2</sub> and SiBr<sub>2</sub>Me–SiBr<sub>2</sub>Me (10%).

# 3.2.4. 1,1,1-tribromotrimethyldisilane, 1,1,1,2-tetrabromodimethyldisilane and pentabromomethyldisilane

The reaction of 2.0 g SiPh<sub>3</sub>SiMe<sub>3</sub> with (a) 5.6 g AlBr<sub>3</sub> and 2.6 g acetylbromide at room temperature, (b) 7.5 g aluminiumbromide and 3.5 g acetyl bromide at 50°C and (c) 9 g aluminiumbromide and 4.2 g acetylbromide (10 h at 120°C) yielded (a) 1.5 g (73%) SiBr<sub>3</sub>SiMe<sub>3</sub>, (b) 1.8 g (74%) SiBr<sub>3</sub>SiBrMe<sub>2</sub> (m.p. 65–68°C) and (c) 2.0 g (70%) SiBr<sub>3</sub>SiBr<sub>2</sub>Me (m.p. 83°C).

## 3.2.5. 2,2-dichlorohexamethyltrisilane

The chlorination of 23 g SiPh<sub>2</sub>(SiMe<sub>3</sub>)<sub>2</sub> with 22.6 g AlCl<sub>3</sub> and 13.4 g acetyl chloride at room temperature provided after distillation 6.2 g (36%) pure SiCl<sub>2</sub>(SiMe<sub>3</sub>)<sub>2</sub> (b.p. 50°C/0.6 kPa). GC/MS (m/e, rel. int.): 244 (M<sup>+</sup>, 5), 229 (Si<sub>3</sub>Me<sub>5</sub>Cl<sub>2</sub>, 3), 209 (Si<sub>3</sub>Me<sub>6</sub>Cl, 1), 151 (Si<sub>2</sub>Me<sub>4</sub>Cl, 4), 136 (Si<sub>2</sub>Me<sub>3</sub>Cl, 39), 131 (Si<sub>2</sub>Me<sub>5</sub>, 9), 93 (SiMe<sub>2</sub>Cl, 8), 73 (SiMe<sub>3</sub>, 100).

This mass spectrum differs significantly from that of 1,3-dichlorohexamethyltrisilane (prepared as described in Ref. [16]): 244 (M<sup>+</sup>, 1), 229 (Si<sub>3</sub>Me<sub>5</sub>Cl<sub>2</sub>, 2), 209 (Si<sub>3</sub>Me<sub>6</sub>Cl, 5), 151 (Si<sub>2</sub>Me<sub>4</sub>Cl, 47), 131 (Si<sub>2</sub>Me<sub>5</sub>, 7), 116 (Si<sub>2</sub>Me<sub>4</sub>, 29), 93 (SiMe<sub>2</sub>Cl, 14), 73 (SiMe<sub>3</sub>, 100).

3.2.6. 1,2,2,3-tetrachlorotetramethyltrisilane and 1,2,2-trichloropentamethyltrisilane

3.0 g SiCl<sub>2</sub>(SiMe<sub>3</sub>)<sub>2</sub> were chlorinated with 6 g AlCl<sub>3</sub> and 3.5 g acetyl chloride and yielded after working up 2.7 g (77%) SiCl<sub>2</sub>(SiClMe<sub>2</sub>)<sub>2</sub> as oily residue. Repetition of this reaction with 4.7 g AlCl<sub>3</sub> and 2.75 g acetyl chloride provided 2.5 g of a mixture of 70% SiCl<sub>2</sub>(SiClMe<sub>2</sub>)<sub>2</sub> with 30% SiClMe<sub>2</sub>-SiCl<sub>2</sub>-SiMe<sub>3</sub>.

# 3.2.7. Tris-(chlorodimethylsilyl)-chlorosilane and tris-(bromodimethylsilyl)-bromosilane

These isotetrasilanes could be obtained from tris-(trimethylsilyl)-phenylsilane:

5.25 g SiPh(SiMe<sub>3</sub>)<sub>3</sub>, 12 g AlCl<sub>3</sub> and 6.25 g acetylchloride provided 3 g (54%) SiCl(SiClMe<sub>2</sub>)<sub>3</sub>.

4.7 g SiPh(SiMe<sub>3</sub>)<sub>3</sub>, 21.6 g AlBr<sub>3</sub> and 8 g acetyl bromide yielded 4 g (53%) SiBr(SiBrMe<sub>2</sub>)<sub>3</sub>.

#### 3.2.8. Decachlorocyclopentasilane

15 g Si<sub>5</sub>Ph<sub>10</sub> were reacted with 32 g aluminiumchloride and 17.5 g acetyl chloride (1 h at 75°C and 10 h at room temperature) to yield 3.5 g (43%) Si<sub>5</sub>Cl<sub>10</sub>.

## 3.3. Hydrogenations with stannanes

The hydrogenations of disilanes were carried out with  $Bu_3SnH$ . So the hydrogenated disilanes as well as formed monosilanes could easily be separated from the catalyst and the formed  $Bu_3SnX$  (X = Cl, Br) by condensation of the silanes into a trap in vacuo at room temperature. Ph<sub>3</sub>P was used as catalyst, because it was known from the hydrogenation of Si<sub>2</sub>Cl<sub>6</sub> that this base is suitable for the hydrogenation of SiCl<sub>3</sub> groups.

In all other hydrogenation reactions (trisilanes, isotetrasilanes as well as cyclopentasilanes) Me<sub>3</sub>SnH was used together with Ph<sub>3</sub>MePI as catalyst. The formed Me<sub>3</sub>SnX have relatively simple <sup>1</sup>HNMR spectra and can easily be removed from high boiling oligosilanes by condensation in vacuo at room temperature. In a typical experiment an amount of 0.5-1 g of the oligosilane was mixed in the desired molar ratio with Me<sub>3</sub>SnH or Bu<sub>3</sub>SnH at room temperature and a trace of the catalyst (1 mol% of the oligosilane) was added. The reaction with stannanes were almost quantitative, that means all R<sub>3</sub>SnH was converted into R<sub>3</sub>SnX (X = Cl, Br) as could be detected by <sup>119</sup>Sn NMR spectroscopy. The isolable yields of hydrogenated oligosilanes were in the range 80–100%.

 $Me_3SnH$  was freshly prepared from  $Me_3SnCl$  and  $LiAlH_4$  in tetraglyme.  $Bu_3SnH$  was commercially available from Merck.

## 3.4. NMR measurements

All NMR measurements were carried out with a BRUKER MSL 300 spectrometer (<sup>29</sup>Si: 59.627 MHz, <sup>1</sup>H: 300.13 MHz). TMS was used as internal standard.

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#### References

- U. Herzog, G. Roewer, U. Pätzold, J. Organomet. Chem. 494 (1995) 143.
- [2] U. Herzog, G. Roewer, E. Brendler, J. Organomet. Chem. 511 (1996) 85.
- [3] U. Herzog, G. Roewer, J. Organomet. Chem. 527 (1997) 117.
- [4] U. Herzog, R. Richter, E. Brendler, G. Roewer, J. Organomet. Chem. 507 (1996) 221.

- [5] U. Pätzold, G. Roewer, U. Herzog, J. Organomet. Chem. 508 (1996) 147.
- [6] Kaczmarczyk, G. Urry, J. Am. Chem. Soc. 82 (1960) 751.
- [7] Trandell, G. Urry, J. Inorg. Nucl. Chem. 40 (1978) 1305.
- [8] U. Herzog, G. Roewer, in: N. Auner, J. Weis (Eds.), Organosilicon Chemistry III, VCH, Weinheim, 1997 (in press).
- [9] E. Hengge, G. Bauer, Monatsh. Chem. 106 (1975) 503.
- [10] C.R. Bettler, J.C. Sendra, G. Urry, Inorg. Chem. 5 (1970) 1060.
- [11] K. Schenzel, K. Hassler, in: N. Auner, J. Weis (Eds.), Organosilicon Chemistry II, VCH, Weinheim, 1996, p. 95.
- [12] J. Zech, H. Schmidbaur, Chem. Ber. 123 (1990) 2087.
- [13] D. Kovar, K. Utvary, E. Hengge, Monatsh. Chem. 110 (1979) 1295.
- [14] G. Fritz, B. Grunert, Z. Anorg. Allg. Chem. 473 (1981) 59.
- [15] U. Herzog, N. Schulze, K. Trommer, G. Roewer, J. Organomet. Chem. (1997) (in preparation).
- [16] H. Gilman, S. Inoue, J. Org. Chem. 29 (1964) 3418.